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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Group:

Mail Stop Patent Application
Commissioner for Patents
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Applicant(s) wish to disclose the following information:

☒ The Applicant(s) wish to make of record the references listed on the attached Form PTO-1449. Copies of the listed references are attached, where required, as are either statements of relevancy or any readily available English translations of pertinent portions of any non-English language references.

☐ A check is attached in the amount required under 37 CFR § 1.17(p).

RELATED CASES

- ☒ Attached is a list of applicant's pending applications or issued patents which are thought to be related to the present application.
- ☐ A check is attached in the amount required under 37 CFR §1.17(p).

CERTIFICATION

The undersigned certifies that

- ☐ Each item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to the filing of this statement
- ☐ No item of information contained in this information disclosure statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the knowledge of the undersigned, having made reasonable inquiry, was known to any individual designated in 37 CFR §1.56(c) more than three months prior to the filing of this statement.

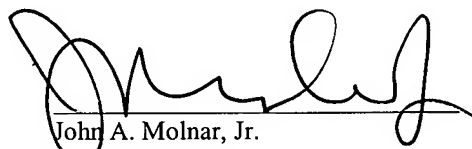
PETITION

- ☐ Applicant(s) hereby request consideration of the attached information. A check is attached in the amount of the Petition fee required under 37 CFR §1.17(i)(1).

DEPOSIT ACCOUNT

- ☒ Please charge any additional fees for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to **Deposit Account No. 16-0325**. A duplicate copy of this sheet is enclosed.

Respectfully submitted



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RELATED CASES

Serial No.	Inventor	Title	Filing Date
60/448,199	Michael H. Bunyan, Thomas A. Clement, John J. Hannafin, Marc E. LaRosee and Kent M. Young	Polishing Article for Electro- Chemical Mechanical Polishing	February 18, 2003

Subst. Form PTO-1449 APPLICANT'S INFORMATION DISCLOSURE STATEMENT	Attorney Docket No. 2802-257-088		Serial No.:
	Applicant: Michael H. Bunyan, et al		
	Filing Date: Concurrently Herewith		Group:

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	FZ	Article from July 2002 Semiconductor Magazine entitled Chemical Mechanical Planar by Katherine Derbyshire.
	GA	Prismark Partners LLC entitled Chemical Mechanical Polishing, dated November 2000.
	GB	Prismark Partners LLC entitled The Semiconductor Equipment Business, dated March 2000.

Examiner:

Date Considered:

*EXAMINER: Initial if reference considered, whether or not citation is in conformation with MPEP 609; draw line through citation if in conformance and not considered. Include copy of this form with next communication to applicant.

360/22971ALA.20G